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electrically coupled to the anode 16. A negative pole 43 of the controller 42 is electrically coupled to the seed layer 15 of the substrate via a plurality of contacts 256 disposed around the periphery of the electrolyte cell.

Please replace the paragraph at page 2, lines 14-24, with the following paragraph:

The embodiment of contacts 256 depicted in FIG. 1 represents a simplified version in which the substrate does not rotate within the substrate support 14. Alternative embodiments of contacts (not shown) are integrated in the substrate support maintaining electric/current applied between the anorle and the seed layer of the

substrate. The electrolyte cell 12 comprises an anode base 90 and an upper container segment 92. The anode 16 is mounted to the anode base 90 by anode supports 94. A feed through 96 supplies electrical power to the anode and the electrical power is

anode base 90 by nuts and boits, screws, or other suitable removable devices to permit the repair and/or replacement of the anode 16 or other components.

narantabh:

The plurality of contacts 250 are configured to contact a plating surface 15 of the substrate that is immersed in an electrolyte solution contained in the electrolyte cell 12 to enable the deposition of metal on the substrate 48. The contacts 256 may take the form of a contact pin, a contact surface, or any known type of electrical contact. The contacts that are mounted about the periphery of a contact ring (not shown) are positioned to minimize irregularities of the electrical field applied to the seed layer formed on the plating surface 15 of substrate 48.

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Please replace the paragraph at page 2, line 32, to page 3, line 9, with the following paragraph:

A substrate support 14 is pivotably mounted above the upper opening and is displaceable between immersed and removed positions. When the substrate support 14 is pivoted into the removed position, the attached substrate is removed upwardly from the electrolyte cell 12. When the substrate support 14 is pivoted into the inserted position, the attached substrate is pivoted downward such that the plating surface 15 of the substrate 48 is immersed in electrolyte solution contained in the electrolyte cell. While in the immersed position, metal ions (typically copper or a copper alloy) contained

The substrate support 14 keeps the substrate connected to the substrate support when desired (for example using vacuum chucking, etc.).

Please replace the paragraph at page 5, line 29 to page 6, line 2, with the

After considering the following-description, those skilled in the art will clearly realize that the teachings of this invention can be readily utilized in metal ion deposition unlimited in at least one aspect, a programmable anode is provided that improves the uniformity of the current density applied across a seed layer on a substrate (e.g., waier).

Please replace the paragraph at page 6, lines 9-16, with the following paragraph:

FIG. 2 is a cross sectional view of a fountain plater 10 having an electroplating cell 200 according to one embodiment of the invention. The electroplating cell 200 comprises the programmable anode 202. The programmable anode 202 is configured to provide for independent control of the electric current passing through certain segments of the anode. The control of individual currents passing through respectiv

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individual segments of the anode provides variation of the electric field in the electrolyte solution contained in the electrolyte cell that can modify the metal deposition uniformity/non-uniformity across the substrate.

Please replace the paragraph at page 6, lines 17-29, with the following paragraph:

In the embodiment shown in FIG. 2, the anode 202 comprises a plurality of anode segments 203a, 203b, 203c, and 203d, with each one of the anode segments formed from such materials as a high purity, oxygen free, copper (Cu). Each one of the about an imaginary adjudent axis 200, and each anode segment. The products

substantially coplanar upper segment surfaces 205a, 205b, 205c, and 205d. While four anode segments 203a, 203b, 203c, and 203d are shown in FIG. 2, any suitable number may be provided. Additionally, each one of the plurality of anode segments 203a, 203b,

207b, 207c, and 207d. Insulating connecting members 210 connect of print ones of the plurality of anode segments 207a, 207b, 207c, and 207d. The anode 202 typically comprises a hydrophilic membrane 87 as shown in the embodiment shown in FIG. 1 and described above, but is not depicted in FIG. 2 for simplicity of discourse.

Please replace the paragraph at page 6, line 30 to page 7, line 12, with the following paragraph:

The anode 202 is configured as a modular assembly that provides for secure positioning and relatively easy replacement of the assembly and the anode segments. Anode support 94 extends between, and is connected to, the anode base 90 and at least one anode segment of the anode 201. Replaceable fasteners such as nuts, bolts, etc. can be used to connect the anode support 94 to the anode base 90 and the anode support 94 to at least one of the anode segment 203a, 203b, 203c, or 203d. Insulative support members 210 physically support each anode segment 203a, 203b, 203c, and

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203d relative to an adjacent anode segment (as shown in FIG. 5). The insulative support member 210 is formed of an insulative material that limits electric current passing between adjacent anode segments 203a, 203b, 203c, and 203d, such that each anode segment can be individually electrically biased to a separate potential. The anode support 94 and the insulative support members 210 interact to maintain each of the anode segments 203a, 203b, 203c, and 203d fixed in position relative to the anode base 90 and the remainder of the electrolyte cell 12 during operation, while keeping each one of the anode segments 203a, 203b, 203c, and 203d relatively insulated from one another and from the cell wall.

paragraphs:

Portions of the anodes 202 are consumed by the electroplating process, resulting in the production of anode sludge. Portions of the anode being consumed results in the

anode is often inconsistent. Therefore, regular anode replacement is necessary to maintain uniform electric field generation within the electrolyte cell. When the anode 202 does become irregularly shaped due to portions of the anode being consumed, or to cause seasons, as a small consumer to capacity and another appearance of the another seasons are the first than the container seasons and the container seasons.

mount 90 after removing the rasteners that connect these two elements. The anode 202 is then disconnected from the anode base 90, and the anode 202 is removed as a modular unit. A replacement modular anode 202 is then inserted and connected to the anode base 90. The upper container segment is then repositioned and fastened to the anode base, and will appear in the assembled position as shown in FIG. 2. In another embodiment, the anode 202 and the anode base 90 can be provided as a single modular unit. In this latter embodiment, another modular anode 202/anode base 90 unit is provided to replace the anode base 90 connected to the consumed anode 202. The upper container segment is then repositioned and fastened to the anode base in the position shown in FIG. 2.

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Please replace the paragraph at page 7, line 31, to page 8, line 11, with the following paragraph:

Each one of the plurality of anode segments 203a, 203b, 203c, and 203d are electrically connected to the controller 254 by respective electrical contacts or feed-throughs 206a, 206b, 206c, and 206d that extend through the electrolyte cell 12 (preferably through the anode base 90). The feed-throughs 206a, 206b, 206c, and 206d are individually insulated by a coating such as an elastomeric or insulative plastic. The coating limits direct chemical or electrical reaction with the electrolyte volution and

members 94 rigidity and insulatively support at least one anothe segment 203a, 203b, 203c, and 203d relative to the electrolyte cell 12. Although the anode segments 203a, 203b, 203c, and 203d are depicted as being cylindrical or ring-shaped, any suitable anode configuration may be utilized where the anode is segmented into a plurality of

be rectangular as depicted in FIG. 6 and described below.

Please replace the paragraph at page 9, lines 4-10, with the following paragraph:

The embodiment of anode 202 shown in FIG. 2 produces an electrical field whose shape can be controllably adjusted. The controllable electrical field produced by the programmable anode 202 results in generation or a controllable electric current density across the seed layer on the substrate. The controller 254 controls the shape of the electromagnetic field generated by the combined effects of the plurality of the individual anode segments 203a, 203b, 203c, and 203d by controlling the electric current supplied to each individual anode segment 203a, 203b, 203c, and 203d.

Please replace the paragraph at page 10, lines 1-13, with the following paragraph:

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The metal ions are dissociated from within a volume of the electrolyte solution (including e.g. copper sulfate) into positively charged copper ions and negatively charged sulfate ions. The copper ions in the region of the substrate/cathode are attracted to the seed layer on the substrate. The excess of sulfate ions remaining in the electrolyte solution contributes to the formation of a depletion region 270 adjacent to the distinct anode segments 203b, 203b, 203c, and 200d. The dissociated motal ions are deposited on the seed layer on the substrate 48. Increasing the electrolyte solution flow from the input port 80 (and the corresponding electrolyte solution output flow over the annular weir portion 82) provides for decreasing the physical size of the depletion region.

The process of dissociating metal ions from the cooper surface continued where the dissociated metal ions may be deposited on the seed layer.

Please replace the paragraph at page 10, lines 14-30, with the following

A reference sensor 250 is shown positioned in close proximity, but spaced from, a substrate 48 positioned for a plating operation (for example, in the contact ring 230). The reference sensor 250 is positioned as far as possible from any postate 253 supplying current/voltage to the substrate. This physical isolation of the reference sensor 250 from contacts 256 limit the electrical effects resulting from a contact that is proximally located to the reference sensor. The electric current density in the seed layer on the substrate is partially determined by an electric field generated in the electrolyte solution contained in the electrolyte cell 12. When the other electrolyte solution properties are held constant, the electric field and the current density generated in the electrolyte solution is controlled by several factors including controlling the electric current flowing through the different ones of the individual anode segments 203a, 203b, 203c and 203d of the anode 202 as well as changing the shape and configuration of the anode. Therefore, the surface potential monitored adjacent the

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surface of the substrate by the reference sensor 250 provides an indication of the effect of the current flowing in the individual anode segments 203a, 203b, 203c, and 203d of the anode 202.

Please replace the paragraph at page 12, lines 19-31, with the following paragraph:

The anode segment 702a can be shifted horizontally to the anode segment 702b in an alternate embodiment of programmable anode, still referring to FIG. 7. Assume that it is determined by the reference sensor 250 that the current density is not at the

The relative positions of the axis 704a and 704b of the anode segment 702a or 702b can be adjusted by loosening a clamping mechanism (not shown) that secures either or both of the anode segments 702a, 702b relatively in position. Anode segment(s) 702a

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segments, the clamping mechanism is reclamped to maintain the anode segments 702a and 702b in position. Additionally, the thickness of certain portions of the anode segments can be altered as shown by arrows 706a and 706b to alter the current density applied to specific locations of the seed layer on the substrate as desired

Please replace the paragraph at page 14, lines 12-28 with the following paragraph:

The instantaneous gradient current density value is a function of the voltage/current in each anode segment as well as the voltage/current in the contacts 256. For example, gradient current density value 806a represents when only the inner anode segment 203a shown in FIG. 2 is energized. Gradient current density value 806b represents when only anode segments 203a and 203b are energized. Gradient current density value 806c represents when only anode segments 203a, 203b, and 203c are energized. Gradient current density value 806d represents when all of the

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anode segments 203a, 203b, 203c, and 203d are energized. As shown in FIG. 8, as different combinations of the anode segments 203a, 203b, 203c, and 203d are energized, the instantaneous gradient current density value will vary. The gradient current density values 806a, 806b, 806c, and 806d shown in FIG. 8 are oppositely in nature, and are provided on a dimensionless scale. The total gradient current density value 808 represents the sum of the instantaneous gradient current density values 806a, 806b, 806c, and 806d for each seed layer location during the period that metal ions are being deposited across the substrate. The total gradient current density values should be substantially constant from the periphery to the center of the seed layer to obscur a uniform capture as a second sec

Please replace the paragraph at page of the 2d to page 15, fire of this distinction following paragraph:

The controller 254 can alter the duration and/or current level applied from each

layer. The non-uniformities exist because the contacts are positioned closer to the periphery 102 of the substrate than the center 104 of the substrate as described above. 203c, and 203d across the width of the programmable anode 202 compensates to provide a uniform outsett landay scross the vidth of the programmable anode 202 compensates to current applied through the individual anode segments 203a, 203b, 203c, and 203d, the current density near the center 104 of the seed layer on the substrate can be adjusted relative to the current density near the periphery 102 of the seed layer on the substrate.

Please replace the paragraph at page 16, lines 3-20, with the following paragraph:

The method 300 then continues to step 304 in which the controller 254 applies electric voltage/current at a prescribed level to actuate the inner anode segment 203a.

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The method 300 then continues to step 306 where the controller 254 waits for a prescribed duration during which time the electric voltage/current applied during step-304 continues to be applied to only the inner anode segment 200a. The application of electric voltage or current to the inner anode negment 200a is maintained until step 210. When only inner anode segment 200a (and not anode segments 200b, 200a, and 200d) is actuated, a higher current density is applied to the center 104 of the seed by with the substrate 48 than to the periphery 102 of the seed layer on the substrate 48. Energizing inner anode segment 200a results in the current density being higher near the center of the seed layer compared to the side of the seed layer. This higher current density multipleadure the inner anode segment 200a is physically located closer to the center.

portions of the seed layer, as described above. During the period that only the inner anode segment 203a is actuated, the rate of metal ion deposition performed within the electroplating cell 200 is higher near to the center 104 of the seed layer 15 of the

Please replace the paragraph at page 20, line 22 to page 21, line 4, with the following paragraph:

The reference sensors 250 may be any of the variety of sensors that can sensor patient, density an tipe and layer on the substrate. It is affect above. Given the controller 254 in this embodiment considers surface potential across the substrate, if only one reference sensor is used, then the surface potential at different locations have to be assumed. Such assumptions can result from an empirical knowledge of the electroplating process, or quantitative measurements at certain locations within the electroplating cell 200 assuming that the measured values do not change. Any variation in monitored electric current values on the substrate 48, as sensed by the reference sensors 250 described above, is fed into the controller 254. The controller 254 alters the electric current applied to the anode segments 203a, 203b, 203c, and 203d to control the electric current density applied across the seed layer on the substrate. The

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embodiment in FIG. 4 is directed at controlling the voltage/current applied to the distinct anode segments 203a, 203b, 203c, and 203d making the sensed current density across the seed layer on the substrate substantially uniform. It is also possible to combine the teachings of the FIG. 4 embodiment with the trackings of the FIG. 0 carbo flowert, as if thus regulating the duration that each anode segment is energized.

Please replace the paragraph at page 21, lines 5-13, with the following paragraph:

The method 100 begins with step 403 in which a substrate to be electroplated is applied to each one of the plurality of anode segments is initially preferably at a single voltage level. Thus, the electric field generated by the anode 202 to the substrate 48 process chamber 223 in the electrolyte solution (such uniformity excludes boundary conditions adjacent the walls).

following paragraph:

Method 400 continues to step 406 in which the controller 254 senses the irregularities in electric field applied to the cathode from the anode, and the resultant surface potential on the surface of the substrate 48. A dummy substrate may be provided having sensors embedded therein such that the dummy substrate is inserted in the electroplating cell in a manner similar to an actual substrate. The anode 202 is then energized, along with electric fields applied to contact points 256. Method 400 continues to step 408 in which the controller 254, based on sensed non-uniformities in the electromagnetic field to the cathode, determines whether to adjust the electric field